	Substitute for form 1449A/PTO							Complete if Known				
	SUPPLEMENTAL							Application Number		10/698,707		
4	E INFORMATION DISCLOSURE							irmation No.	1922			
١,	STATEMENT BY APPLICANTS						Filing Date First Inventor		October 31, 2003 Hironori SUMITOMO et al			
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	Examiner Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, so symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published											
	D	Notification of Reason(s) for Refusal, dated September 13, 2005, for counterpart Japanese Patent Application No. 2003-191809; along with an English-language translation thereof									Application	
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<sup>\*</sup>EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Dray line through citation if not in conformance and not considered. Include copy of this form with the next communication to applicant.